Application No.: 10/754348 Docket No.: EL0538USNA

Docket No.: EL0538USNA Page 2 Confirmation No.: 8319

Amendments to Claims

This listing of claims replaces all prior versions and listings of claims in the application.

1. (Currently Amended) A composition consisting of :

a polymer with a glass transition temperature greater than 310°C and a water absorption of 2% or less;

one or more metals or metal compounds; and an organic solvent;

wherein said polymer is a polynorbornene comprising <u>as depicted by</u> molecular units of formula I

$$\mathbb{R}^1$$
 I

wherein R^1 is independently selected from hydrogen and a (C_1-C_{10}) alkyl.

2.-4. (Cancelled)

5. (Original) The composition of claim 1 wherein the water absorption is 1% or less.

6.-7. (Cancelled)

8. (Previously Presented) The composition of claim 1 wherein the polymer is a polynorbornene that further consists of molecular units of formula II

$$\mathbb{R}^2$$
 II

wherein R² is a pendant group capable of participating in a cross-linking or network-forming reaction selected from the group consisting of: epoxides, alcohols,

Application No.: 10/754348

Docket No.: EL0538USNA

Page 3

Confirmation No.: 8319

silyl ethers, carboxylic acids, esters, and anhydrides; and the molar ratio of molecular units of formula I is greater than 0 to about 0.4.

9. (Cancelled)

10. (Original) The composition of claim 1 wherein the polymer contains sites

that can crosslink with one or more crosslinking agents.

11. (Cancelled)

12. (Cancelled)

13. (Cancelled)

14. (Cancelled)

15. (Cancelled)

16. (Previously Presented) The composition of claim 1 wherein the composition is used to make an electronic component selected from the group

consisting of resistors and discrete or planar capacitors.

17. (Previously Presented) The composition of claim 16 wherein the electronic

component is a resistor with a percent resistance change of less than ±5% with

respect to the relative humidity test.

18. (Previously Presented) The composition of claim 17 wherein the resistor

exhibits a percent resistance change of less than ±1% with respect to an electrostatic

discharge test.

19. (Previously Presented) The composition of claim 16 wherein the electronic

component is a discrete or planar capacitor with a capacitance percent loss of less

than 5%.

Application No.: 10/754348

Docket No.: EL0538USNA

Page 4

Docket No.: EL0538USNA Page Confirmation No.: 8319

20. (Original) The composition of claim 1 wherein the composition is used to prepare a conductive adhesive.

- 21. (Original) The composition of claim 1 wherein the composition has a cure temperature of less than 180°C or can be cured at a peak temperature up to about 270°C with a short infrared cure.
- 22. (Currently Amended) A composition consisting of a polymer with a glass transition temperature greater than 310°C and a water absorption of 2% or less, and an organic solvent wherein said polymer is a polynorbornene comprising as depicted by molecular units of formula I

$$\mathbb{R}^1$$
 I

wherein R^1 is independently selected from hydrogen and a (C_1-C_{10}) alkyl.

- 23. (Cancelled)
- 24. (Original) The composition of claim 22 wherein the composition has a cure temperature of less than 180°C or can be cured at a peak temperature up to about 270°C with a short infrared cure, and the composition is used as an encapsulant or an integrated circuit and wafer-level package selected from semiconductor stress buffers, interconnect dielectrics, protective overcoats bond pad redistribution, or solder bump underfills.
- 25. (Previously Presented) A method of making a PTF resistor comprising: combining a polymer with a glass transition temperature greater than 310°C and a water absorption of less than 2%, one or metals or metal compounds, and an organic solvent to provide a PTF resistor composition;

applying the PTF resistor composition to a substrate; and curing the applied PTF resistor composition; and

Application No.: 10/754348 Docket No.: EL0538USNA

Docket No.: EL0538USNA Page 5 Confirmation No.: 8319

wherein the polymer is a polynorbornene consisting of molecular units of formula I

$$R^1$$
 I

wherein R¹ is independently selected from hydrogen and a (C₁-C₁₀)alky.

- 26. (Cancelled)
- 27. (Original) The method of claim 25 wherein the curing of the applied PTF resistor composition includes a cure temperature of less than 180°C or a peak temperature up to about 270°C with a short infrared cure.
 - 28. (Cancelled)
- 29. (Original) The method of claim 25 wherein the polymer has a water absorption of 1% or less.
 - 30. (Cancelled)
- 31. (Previously Presented) The method of claim 25 wherein the polymer is a polynorbornene that further consists of molecular units of formula II

$$\mathbb{R}^2$$
 II

wherein R² is a crosslinkable epoxy group, and the molar ratio of molecular units of formula II to formula I is greater than 0 to about 0.4.

32. (Cancelled)

Application No.: 10/754348

Docket No.: EL0538USNA

Page 6

Confirmation No.: 8319

33. (Previously Presented) An electronic component selected from the group consisting of PTF resistors and discreet or planar resistors, wherein the electronic component comprises a cured composition prepared by a process comprising:

combining a polymer with a glass transition temperature greater than 310°C and a water absorption of 2% or less, one or metals or metal compounds, and an organic solvent to provide an uncured composition;

applying the uncured composition to a substrate; and curing the applied composition; and

wherein the polymer is a polynorbornene consisting of molecular units of formula I

$$\mathbb{R}^1$$

wherein R¹ is independently selected from hydrogen and a (C₁-C₁₀)alky.